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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO	
09/609,250	06/30/2000	Tsuguhiro Korenaga	33216M050	2081	
75	90 03/26/2002				
Beveridge DeGrandi weilacher & Young LLP			EXAMINER		
Suite 800 1850 M Street 1		VARGOT, MATHIEU D			
Washington, Do	20036		ART UNIT	PAPER NUMBER	
			1732	2	
			DATE MAILED: 03/26/2002	\mathcal{O}	

Please find below and/or attached an Office communication concerning this application or proceeding.

•	Application No.	Applicant(s)						
Office Action Cummons	09/609,250	K	ORENA 6A	et	cl,			
Office Action Summary	Examiner		Group Art Unit					
	M. VAR607		1732					
—The MAILING DATE of this communication appears on the cover sheet beneath the correspondence address—								
Period f r Reply								
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO OF THIS COMMUNICATION.	EXPIRE 3	MONTH(S)	FROM THE MAIL	ing dat	ΓÉ			
 Extensions of time may be available under the provisions of 37 CFR 1.13 from the mailing date of this communication. If the period for reply specified above is less than thirty (30) days, a reply If NO period for reply is specified above, such period shall, by default, ex Failure to reply within the set or extended period for reply will, by statute, 	within the statutory minimupire SIX (6) MONTHS from	um of thirty (30) on the mailing date	days will be considere	ed timely. en .	HS _.			
Status								
☐ Responsive to communication(s) filed on				•				
☐ This action is FINAL .								
 Since this application is in condition for allowance except fo accordance with the practice under Ex parte Quayle, 1935 			the merits is clos	ed in				
Disp sition of Claims								
X Claim(s)		is/are p	ending in the appl	ication.				
Of the above claim(s)	is/are v	is/are withdrawn from consideration.						
□ Claim(s)	is/are a	is/are allowed.						
✓ Claim(s)	•	is/are r	ejected.					
☐ Claim(s)		is/are c	bjected to.					
□ Claim(s)		are sub	eject to restriction	or electio	n			
Application Papers		roquire	mont.					
☐ See the attached Notice of Draftsperson's Patent Drawing F	Review, PTO-948.							
☐ The proposed drawing correction, filed on is ☐ approved ☐ disapproved.								
☐ The drawing(s) filed on is/are objected to by the Examiner.								
\Box The specification is objected to by the Examiner.								
☐ The oath or declaration is objected to by the Examiner.								
Pri rity under 35 U.S.C. § 119 (a)-(d)								
Acknowledgment is made of a claim for foreign priority under All Some* None of the CERTIFIED copies of the Teceived. received in Application No. (Series Code/Serial Number) received in this national stage application from the International	e priority documents ha	ve been						
*Certified copies not received:								
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Attachment(s)	5+6 ==	dominu Cur	nary, PTO-413					
				ion PTO	L1E2			
Notice of Reference(s) Cited, PTO-892		Notic of Informal Patent Application, PTO-152 Other						
☐ Notice of Draftsperson's Patent Drawing R vi w, PTO-948		uler						
Office Acti n Summary								

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1. The following is a quotation of the first paragraph of 35 U.S.C. 112:

The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.

Claims 1-11 are rejected under 35 U.S.C. 112, first paragraph, as containing subject matter which was not described in the specification in such a way as to reasonably convey to one skilled in the relevant art that the inventor(s), at the time the application was filed, had possession of the claimed invention. Applicant has disclosed that T₁ constitutes a temperature "for pressing the mold against the base material" (page 7, line 2) and at page 14, lines 2-3, the molding temperature. Also, T₂ is disclosed as the temperature "for separating the mold from the base material" at page 7, line 3 and the mold releasing temperature at page 14, line 3. While applicant has disclosed that the two molds are heated and therefore the base material itself is also heated, applicant has failed to describe exactly what is meant by "temperature for pressing" and "temperature for releasing". It is not clear from the specification if the temperatures referred to are mold or substrate temperatures.

2. Claims 1-11 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

In claim 1, is the temperature T₁ (ie, for pressing the mold against the base material) the temperature of the top mold, bottom mold or the substrate? Ie, it is unclear exactly what constitutes this temperature and whether such is the "molding temperature" set forth in the instant

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specification. Also, what exactly constitutes the temperature for separating the mold from the base material--does applicant mean the temperature of the substrate or the temperature of one of the molds? Claim 9 is indefinite in calling for an apparatus "wherein a micro-shape is transcribed in accordance with...claim 1 or 2" when in fact the method does not further define the apparatus.

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the

basis for the rejections under this section made in this Office action:

Applicant is requested to make claim 9 an independent claim.

A person shall be entitled to a patent unless --

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1-5, 7 and 10 are rejected under 35 U.S.C. 102(b) as being anticipated by Greschner et al (see passage bridging columns 2 and 3 for the dimensions; col. 4, lines 36-45 for the temperatures; col. 5, lines 30-32 for the thermal expansion coefficients).

The applied reference discloses the instant process for a micro-shape transcription using a mold stamper with a thermal expansion coefficient very close to that of the base material (silicon) being molded so that the instant relations (1) and (2) are satisfied. This is so because the molding temperature (T_1) is around 600 deg C, the releasing temperature (T_2) is 380-450 deg C and the absolute value of the difference of the thermal expansion coefficients of the mold stamper and base is 1 exp (-6). Employing these numbers and figuring that d = 2 mm, the product of relation (2) is 3 exp (-4), which is less than or equal to 4 exp (-2). Any value of d that would correspond

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to any conventional optical disk would yield a value for relation (2) which is less than or equal to 4 exp (-2), and hence claim 1 is anticipated.

- 4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 6, 8, 9 and 11 are rejected under 35 U.S.C. 103(a) as being unpatentable over Greschner et al.

Greschner et al discloses the basic claimed method and apparatus lacking essentially the exact depth of the pattern, the use of thermoplastic resins as the base material, the employment of vacuum chucks to keep the base in place and making a waveguide by the pressing process. Note that Greschner et al (col. 3, line 1) teaches that the depth of the pattern would be 600 nm, or .6 um, such seen to have been an obvious depth over the instantly claimed 1 um or more. As noted in the background portion of the instant specification (ie, The Related Art section), it is well known to make glass waveguides and transcribe micro-patterns by pressing resin substrates. It is submitted that these aspects would have been well known to those of ordinary skill in this art and obvious modifications to the process of the applied reference dependent on the exact optical article desired. Greschner et al shows air passages (39 in Fig. 3) which are taught as connected to a source of compressed air to release the pressed base material from the bottom mold. However, attachment by vacuum is nothing but conventional in this art and one of ordinary skill would have

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recognized that passages 39 would have equally have been used in a vacuum pinning operation.

Ie, it would have been obvious to have modified bottom mold 38 as a vacuum chuck as called for

in instant claim 9 to facilitate its accurate placement before pressing.

5. Any inquiry concerning this communication or earlier communications from the examiner

should be directed to M. Vargot whose telephone number is (703) 308-2621.

Any inquiry of a general nature or relating to the status of this application or proceeding

should be directed to the receptionist whose telephone number is (703) 308-0661.

M. Vargot

March 21, 2002

MATHIEU D. VARGOT PRIMARY EXAMINER GROUP 1300 Page 5

3/21/02